This article was downloaded by:

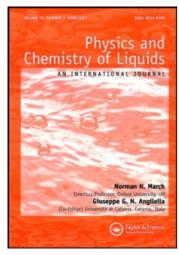
On: 28 January 2011

Access details: Access Details: Free Access

Publisher Taylor & Francis

Informa Ltd Registered in England and Wales Registered Number: 1072954 Registered office: Mortimer House, 37-

41 Mortimer Street, London W1T 3JH, UK



Physics and Chemistry of Liquids

Publication details, including instructions for authors and subscription information: http://www.informaworld.com/smpp/title~content=t713646857

Editorial board page for "Physics and Chemistry of Liquids", Volume 25, Number 4

To cite this Article (1993) 'Editorial board page for "Physics and Chemistry of Liquids", Volume 25, Number 4', Physics and Chemistry of Liquids, 25: 4, a

To link to this Article: DOI: 10.1080/00319109308030362 URL: http://dx.doi.org/10.1080/00319109308030362

PLEASE SCROLL DOWN FOR ARTICLE

Full terms and conditions of use: http://www.informaworld.com/terms-and-conditions-of-access.pdf

This article may be used for research, teaching and private study purposes. Any substantial or systematic reproduction, re-distribution, re-selling, loan or sub-licensing, systematic supply or distribution in any form to anyone is expressly forbidden.

The publisher does not give any warranty express or implied or make any representation that the contents will be complete or accurate or up to date. The accuracy of any instructions, formulae and drug doses should be independently verified with primary sources. The publisher shall not be liable for any loss, actions, claims, proceedings, demand or costs or damages whatsoever or howsoever caused arising directly or indirectly in connection with or arising out of the use of this material.

PHYSICS AND CHEMISTRY OF LIQUIDS AN INTERNATIONAL JOURNAL

N. H. MARCH Editor

Department of Theoretical Chemistry, University of Oxford, 5 South Parks Road, Oxford OXI 3UB, Great Britain

EDITORIAL ADVISORY BOARD

C. F. CURTISS
University of Wisconsin, Madison,

Wisconsin, USA
N. E. CUSACK
University of East Anglia, Norwich, England,

Great Britain
P. A. EGELSTAFF
University of Guelph, Guelph, Ontario, Canada

H. ENDO
University of Kyoto, Kyoto, Japan
J. FRIEDEL
University of Paris, Orsay, France

K. E. LARSSON Royal Institute of Technology, Stockholm, Sweden M. MANDEL
Rijksuniversiteit te Leiden, Leiden,
The Netherlands

I. PRIGOGINE
Faculté des Sciences, Bruxelles, 1050 Belgium
and University of Texas, Austin, Texas, USA

S. STEEB

Max Planck Institut für Metallforschung,
Stuttgart, Germany
N. J. TRAPPENIERS

N. J. TRAPPENIERS

Universiteit van Amsterdam, Amsterdam,
The Netherlands